

OPTICAL MODULATION ELEMENT AND PROJECTION APPARATUS

BACKGROUND OF THE INVENTION

Field of the Invention

5 The present invention relate to an optical modulation element and a projection apparatus using the optical modulation element.

Related Background Art

10 Conventionally, a reflection diffraction grating type optical modulation element as shown in the perspective view of Fig. 3 has been proposed.

15 Fig. 3 shows a light modulator (optical modulation element) whose surface (reflecting surface) three-dimensionally deforms and has strip-shaped elements 31 each made of a thin film in a one-dimensional array on a substrate 30. Four strip-shaped elements 31 correspond to one picture element. The strip-shaped elements 31 are provided in a number corresponding to the picture elements in the horizontal direction.

20 The substrate 30 can be formed using, e.g., silicon. A conductive layer 34 made of, e.g., tungsten or a tungsten alloy is formed on the substrate via a passivation layer (not shown) made of, e.g., silicon nitride (Si_3N_4). Each strip-shaped element 31 can be formed from, e.g., silicon nitride and has its two ends fixed on the substrate 30 at positions separated from

the conductive layer 34. An intermediate flat portion 32 is spaced apart from the substrate 30 while forming a gap 33. The upper surface of the flat portion 32 is coated with a light reflecting material such as an
5 aluminum film.

The thickness of the gap 33 can be adjusted by changing the magnitude of a voltage to be impressed between the strip-shaped element 31 and the conductive layer 34. When no voltage is impressed, the
10 strip-shaped element 31 projects, as shown in Fig. 4A. When an appropriate voltage is impressed between the strip-shaped element 31 and the conductive layer 34, the strip-shaped element 31 deforms due to electrostatic attraction, so the flat portion 32 of the
15 strip-shaped element 31 bends toward the substrate 30 and comes into contact with the substrate 30, as shown in Fig. 4B.

Assume that all strip-shaped elements 31 project, as shown in Fig. 4A. When light having a wavelength λ becomes perpendicularly incident on the surface of the substrate 30, all reflected light components from the element flat portions 32 of the strip-shaped elements 31 are in phase, and four elements 31 which form one picture element functions as a flat mirror.
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25 Assume that four strip-shaped elements 31 alternately exhibit projecting and recessed shapes, and for example, the height difference between the

projecting portion and the recessed portion is $\lambda/4$.

When light having the wavelength λ becomes perpendicularly incident on the surface of the substrate 30, the phase of reflected light from each

- 5 projecting portion surface is shifted from that of reflected light from each recessed portion surface by $\lambda/2$, as shown in Fig. 6. Interference occurs between these reflected light components, so the reflected light emerges from the surface as reflected diffraction
- 10 light having an angle θ with respect to a line perpendicular to the surface.

Hence, for example, when a lens for focusing light reflected at the angle θ is arranged, an arbitrary one of the plurality of picture elements can be displayed

- 15 as a dark picture element by modulating four strip-shaped elements 31 corresponding to that picture element to the state shown in Fig. 5, and an arbitrary one of the plurality of picture elements can be displayed as a bright picture element upon receiving
- 20 light by modulating four strip-shaped elements 31 corresponding to that picture element to the state shown in Fig. 6. Fig. 7 is a graph showing the impressed voltage vs. intensity of reflected light characteristic of a reflection diffraction grating
- 25 having the above structure.

In the above prior art, however, a fixing portion 301 for supporting and fixing the effective reflecting

portion 32 on the substrate 30 is necessary, as shown in Fig. 3 or 4A and 4B. Since the size of the fixing portion 301 is 20 μm or more, light incident on the fixing portion 301 causes flare. Additionally, in the above prior art, since the strip-shaped elements cannot be made compact in the longitudinal direction, the two-dimensional array of elements reduces the aperture ratio of the picture elements.

10 SUMMARY OF THE INVENTION

It is an object of the present invention to provide an optical modulation element and a projection apparatus using the optical modulation element, which can eliminate or reduce flare.

15 The present invention discloses the following arrangements (1) to (10).

(1) An optical modulation element capable of forming a reflective diffraction grating in which heights of a plurality of elements each having a reflecting surface periodically change,

wherein the reflecting surfaces of at least one of the plurality of elements are driven in a direction of height by piezoelectric element.

(2) In the optical modulation element according to (1), the plurality of elements each having the reflecting surface are two-dimensionally arrayed by juxtaposing long sides.

(3) In the optical modulation element according to
1 (1) or (2), said plurality of elements are respectively
provided with the piezoelectric elements the polarities
of electric fields of which are alternately different
5 from each other.

(4) In the optical modulation element according to
10 (3), a rear surface side of an effective reflecting
portion of each of the elements is fixed to the
piezoelectric element.

15 (5) In the optical modulation element according to
(3) or (4), a deformation amount of a projecting and/or
recessed shape of each element is changed by adjusting
a voltage to be impressed to the piezoelectric element,
thereby controlling an intensity of reflected light.

20 (6) In the optical modulation element according to
any one of (1) to (4), when the reflecting surfaces of
the plurality of elements are substantially flush with
each other, said reflecting surfaces act as a flat
mirror as a whole.

25 (7) In the optical modulation element according to
any one of (1) to (6), each of the elements is a
strip-shaped element having a width of about 5 μm .

(8) In the optical modulation element according to
any one of (1) to (7), an interval between adjacent
elements is minimized as much as possible.

(9) In the optical modulation element according to
claim any one of (1) to (8), pixels each formed from

the plurality of elements are arranged in a two-dimensional array.

(10) A projection apparatus including an optical modulation element for modulating incident light in accordance with a video signal, wherein the optical modulation element is formed from the optical modulation element of any one of (1) to (9).

In the embodiment to be described below, the fixing portion 301 as in the prior art can be omitted by applying the above arrangements, so the flare can be prevented. In addition, even when picture elements are arranged in a two-dimensional array, the aperture ratio can be made high.

15 BRIEF DESCRIPTION OF THE DRAWINGS

Fig. 1 is a perspective view showing the structure of an optical modulation element according to the embodiment of the present invention;

20 Fig. 2 is a view showing the arrangement of a projection apparatus using the element according to the embodiment;

Fig. 3 is a perspective view showing the structure of a conventional optical modulation element;

25 Figs. 4A and 4B are views for explaining the function of the conventional optical modulation element, in which Fig. 4A is a view for explaining an unimpressed state, and Fig. 4B is a view for explaining

an impressed state;

Fig. 5 is a view for explaining an unmodulated state of the strip-shaped elements of the optical modulation element;

5 Fig. 6 is a view for explaining a modulated state of the strip-shaped elements of the optical modulation element; and

10 Fig. 7 is a graph showing the impressed voltage vs. intensity of reflected light characteristic of the optical modulation element.

DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENTS

The embodiment of the present invention will be described below.

15 Fig. 1 is a perspective view showing the structure of an optical modulation element according to the embodiment of the present invention, which can form a reflective diffraction grating.

20 Referring to Fig. 1, the optical modulation element comprises aluminum portions 101 each serving as a mirror that forms an effective reflecting portion, metal members 102, metal electrodes 107, piezoelectric materials 103, metal electrodes 104, a support member 105, and a substrate 106.

25 In this embodiment, charges are applied to the piezoelectric material inserted between the metal electrodes 104 and 107 to expand/contract the

piezoelectric material, thereby causing the above-described change in the gaps between adjacent effective reflecting portions.

That is, when the piezoelectric material 103 is charged, and the polarity of the electric field matches that of the piezoelectric material, the material contracts. If the polarity of the electric field is opposite to that of the piezoelectric material, the material expands. Hence, the plurality of mirror portions 101 move upward/downward upon charging to alternately change their heights, so that a reflection type diffraction grating or a mere flat mirror can appear. The degree of modulation of reflected light by the diffraction grating can be adjusted by changing the height of the recessed or projecting portion of the reflection type diffraction grating to change the phase difference between adjacent light components.

As shown in Fig. 1, since the mirror 101 itself that forms the effective reflecting portion is fixed on the substrate through the driving portion, no wasteful fixed portion need be prepared, unlike the prior art. Hence, an optical modulation element capable of obtaining a high aperture ratio even in use of a two-dimensional array and eliminating flare can be formed.

Fig. 2 is a view showing the arrangement of a projection apparatus using the element according to

this embodiment.

Referring to Fig. 2, the projection apparatus comprises an optical modulation element 201 that can form a reflective diffraction grating, a light source 202, lens 203, half mirror 208, projection lens 209, and stopper 210.

Light emitted from the light source 202 is converted into parallel light by the lens 203, reflected by the half mirror 208, and enters the optical modulation element 201.

On the other hand, a modulation signal (voltage pulse) is applied from a driver 1 to each strip-shaped element of the optical modulation element 201 in accordance with a video signal to modulate each element in accordance with the luminance of a corresponding picture element in the horizontal direction (vertical direction in the drawing).

When four strip-shaped elements corresponding to an arbitrary picture element are in the state (unmodulation state) shown in Fig. 5, the light propagates back along the optical path of incident light 204 without any diffraction, changes to a light beam 207 through the half mirror 208, is focused to the focal point of the projection lens 209 as a light beam 213, and absorbed by the stopper 210.

When four strip-shaped elements corresponding to an arbitrary picture element are in the state

(modulation state) shown in Fig. 6, the height of the grating 201 of the optical modulation element is $\lambda/4$, and diffraction occurs. The reflected light emerges in a direction different from that of incident light 205, 5 changes to a light beam 206 through the half mirror 208, and changes to a light beam 212 through the projection lens 209, with which a predetermined horizontal line on a display plane 5 is irradiated through a galvanomirror (not shown). The galvanomirror 10 is a scanner for scanning the incident light beam in a direction perpendicular to the horizontal line to display a desired image.